1 **Multifunctional ytterbium oxide buffer for perovskite solar cells**

16 Ontario M5G 3E4, Canada

 Perovskite solar cells (PSCs) comprise a solid perovskite absorber sandwiched between multiple layers of different charge-selective materials, ensuring unidirectional current flow and high voltage output of the devices1,2 . A "buffer material" between the electron-selective layer (ESL) and the metal electrode in p- type/intrinsic/n-type (p-i-n) PSCs (also known as inverted PSCs) allows electrons to flow from the ESL to the electrode3-5 . Also, it acts as a barrier inhibiting the inter- diffusion of harmful species in or degradation products out of the perovskite absorber6-8 . Thus far, evaporable organic molecules9,10 and atomic-layer-deposited metal oxides11,12 have proven successful, but each has specific imperfections. Here, we report a chemically stable and multifunctional buffer material, ytterbium oxide (YbO*x***), for p-i-n PSCs** *via* **scalable thermal evaporation deposition. We employed this YbO***^x* **buffer into the p-i-n PSCs with a narrow-bandgap (NBG) perovskite absorber, yielding a certified power conversion efficiency (PCE) of over 25%. We also demonstrate the broad applicability of YbO***^x* **in enabling highly efficient PSCs from various types of perovskite absorber layers, delivering state-of-the-art efficiencies of 20.1% for the wide-bandgap (WBG) perovskite absorber and 22.1% for the mid-bandgap (MBG) perovskite absorber, respectively. Moreover, when subjected to**

- **ISOS-L-3 accelerated ageing, encapsulated devices with YbO***^x* **exhibit markedly**
- **enhanced device stability.**
-

 The PCE of single-junction p-i-n PSCs (also referred to as inverted PSCs) has surpassed 25% through passivation methodologies^{3-5,13-15}. However, the published operational stability of p-i-n PSCs under stringent test conditions still lags behind commercially viable solar panels¹⁶⁻¹⁸. Though multiple factors are responsible for device degradation under 59 operating conditions¹⁹⁻²¹, ion migration under realistic operational conditions represents a significant challenge as it is almost ubiquitous within a device. Electrical bias and illumination-induced ion migration within a perovskite absorber layer can inevitably vary 62 the chemical composition at the nano- and micro-scale^{19,21,22}, inducing higher chemical heterogeneity, increased non-radiative recombination centers and subsequent initial sites 64 where device degradation occurs^{2,23}. Furthermore, these mobile ions from the perovskite absorber can diffuse into the charge-selective layers and may accumulate at the metal electrode interface. The accumulated ions have been proven to corrode the metal electrodes^{7,24}, damaging the integrity of the metal electrode and degrading device stability. Another key concern for long-term instability is the metal diffusion into the electron- selective and perovskite layers, which may lead to the formation of metal halides and 70 weakened device stability^{7,25,26}.

 Attempting to introduce an effective buffer layer between the ESL and the metal electrode to block atom and ion movement between the perovskite and metal layers (in both directions, **Extended Data Fig. 1a**) is of technological interest in improving overall device

Properties of ytterbium oxide

93	Yb with a low Gibbs free energy has a strong tendency to form YbO_x when exposed to
94	oxygen (Supplementary Note 1, Extended Data Fig. 1b). The YbO_x that can be processed
95	with thermal evaporation (Extended Data Fig. 1c) shows great promise of commercial
96	applications (Supplementary Note 2, Supplementary Tables 1 and 2). To understand the
97	oxidation of Yb, we first thermally evaporated a few nanometers of Yb films on a large-
98	scale indium tin oxide (ITO) substrate (100 cm^2) in the device fabrication vacuum chamber
99	with a base pressure of 10^{-4} Pa. The sampling data from different areas of the sample shows
100	identical YbO_x states (Extended Data Fig. 2). This rapid oxidation associated with metal
101	Yb is further demonstrated by the color change of the polished Yb metal surfaces before
102	and after oxidation (Extended Data Fig. 3). We then studied the detailed oxidation
103	dynamics of the clean Yb^0 surface by tracking the oxidation process over time using in-situ
104	photoelectron X-ray spectroscopy (XPS) (Extended Data Fig. 4, Supplementary Table
105	3). These results indicate that the Yb film (with a thickness of a few nanometers) deposited
106	on the large-area ITO substrate can be fully oxidized in a few minutes when upscaling in a
107	device fabrication vacuum chamber with a base pressure of 10^{-4} Pa (see details in
108	Supplementary Note 3). Such benefits eliminate the additionally dedicated oxidation step,
109	which is usually required for other oxides processed with thermal evaporation ³⁰ .

 Fig. 1a-c shows the high-resolution TEM (HRTEM) images and the corresponding fast Fourier transform (FFT) patterns of the Yb film. The HRTEM images and FFT patterns

Multifunctional role of interfacial YbO*^x*

 Fig. 2 shows XPS data on the variation of chemical constituents in the electron-selective layer and its interface with the metal electrode measured from samples with (target) and

sample without YbO*^x* (**Supplementary Fig. 5**). One such variation brings a positive impact

on electron collection at the Cu electrode interface. To reveal the charge-carrier transport

165 properties of the YbO_x buffer, two devices with 20 alternative layers of YbO_x (2 nm) and

- YbO*^x* (5 nm)/Cu (1 nm) [for example, ITO/[YbO*^x* (2 nm)]20/Cu (100 nm) and ITO/[YbO*^x*
- 167 (5 nm)/Cu (1 nm)]₂₀/Cu (100 nm)] were prepared. We confirm that the YbO_x used in the
- charge-carrier transport measurements shows no metallic states and instead exhibits a

 considerable density of in-gap states near the Fermi level (**Extended Data Fig. 7a, b**). By measuring the temperature dependence of current density*−*voltage (*J−V*) characteristics of 171 the devices with $ITO/[YbO_x(2 \text{ nm})]_{20}/Cu$ (100 nm) and $ITO/[YbO_x(5 \text{ nm})/Cu$ (1 nm)]₂₀/Cu (100 nm) (**Extended Data Fig. 7c, d** and **Extended Data Fig. 8**), we find that the charge- carrier transport inside the YbO*^x* follows a phonon-assisted electron hopping from one localized state to another rather than through the drift of Bloch wave described in the typical energy-band theory (**Supplementary Note 4)**. This physical process was originally 176 proposed by Mott³⁷, who gave the temperature-conductivity dependence law below:

177
$$
\sigma = \sigma_0 \exp(-B/T^{\frac{1}{4}})
$$
 (1)

178 where σ_0 is a pre-factor, and *B* depends on the radial extension of the wave functions and density of states. Herein, we illustrate phonon-assisted electron hopping *via* unoccupied 180 localized states of the YbO_x buffer layer when electrons flow from C₆₀ to Cu (**Fig. 3a**).

Photovoltaic performance enhancement

 To assess the impact of the YbO*^x* buffer layer on device performance, we fabricated full devices using perovskites with three different typical bandgaps. The cross-sectional and top-view SEM images for these perovskites are shown in **Supplementary Fig. 6**. **Supplementary Fig. 7** displays the optoelectronic properties of the associated perovskites with various bandgaps. Firstly, we evaluated the photovoltaic performances of the p-i-n PSCs based on an NBG perovskite absorber [Rb0.05Cs0.05MA0.05FA0.85Pb(I0.95Br0.05)3]. The

Thermal and operational stability

241 output under 1-sun illumination with and without thermal stress. The tested PSCs were also encapsulated and continuously illuminated by a white light-emitting diode (LED) array 243 with an intensity equivalent to 100 mW cm^{-2} of AM 1.5G irradiance without active cooling. The most stable NBG-based device with YbO*^x* maintained its initial performance for 800

 To gain more insights into the device stability improvements, we then conducted time-of- flight secondary ions mass spectrometry (TOF-SIMS) measurements on full PSC devices with BCP or YbO*^x* before and after ageing. Combining the TOF-SIMS with the depth-

- 34 Hu, J. T. *et al.* Damage-free depth profiling of electronic structures in multilayered
- organic semiconductors by photoelectron spectroscopy and cluster ion beam. *Phys.*
- *Status Solidi B* **258,** 2100130 (2021).
- 35 Chen, P. *et al.* Refining perovskite heterojunctions for effective light-emitting solar cells. *Adv. Mater.* **35,** 2208178 (2022).
- 36 Greiner, M. T., Chai, L., Helander, M. G., Tang, W.-M. & Lu, Z.-H. Metal/metal-
- oxide interfaces: How metal contacts affect the work function and band structure
- of MoO3. *Adv. Funct. Mater.* **23,** 215-226 (2013).
- 37 Mott, N. Electrons in glass. *Nature* **257,** 15-18 (1975).
- 38 Oliver, R. D. J. *et al.* Understanding and suppressing non-radiative losses in
- methylammonium-free wide-bandgap perovskite solar cells. *Energy Environ. Sci.*
- **15,** 714-726 (2022).
- 39 Tong, J. *et al.* Wide-bandgap metal halide perovskites for tandem solar cells. *ACS*
- *Energy Lett.* **6,** 232-248 (2020).
- 40 Ganose, A. M., Scanlon, D. O., Walsh, A. & Hoye, R. L. Z. The defect challenge
- of wide-bandgap semiconductors for photovoltaics and beyond. *Nat. Commun.* **13,** 1-4 (2022).
- 41 Tremblay, M.-H. *et al.* Benzocyclobutene polymer as an additive for a benzocyclobutene-fullerene: Application in stable p-i-n perovskite solar cells. *J.*
- *Mater. Chem. A* **9,** 9347-9353 (2021).

 Fig. 1 | **Characterization of YbO***^x* **films**. **a**, A general high-resolution transmission electron microscopy (HRTEM) image of the pure ytterbium film. The magnified HRTEM image (**b**) and the corresponding fast Fourier transform (FFT) patterns (**c**) of the red squared area selected in (**a**). X-ray photoemission spectroscopy (XPS) spectra of the Yb 4d corresponding to the Yb^{3+} state (**d**) and O 1s (**e**). **f**, The reflection electron energy loss 366 spectroscopy (REELS) spectrum of the YbO_x film. The inset shows how the band gap is determined. **g**, Ultraviolet photoelectron spectroscopy (UPS) spectra of the YbO*^x* film. Left, secondary electron cut-off (SECO) spectrum. Right, valence band (VB) spectrum. **h**, 369 Energy levels of the YbO_x film. Key parameters shown are E_{CBM} (conduction band 370 minimum), E_{VBM} (valence band maximum), E_F (Fermi level), and E_{VAC} (vacuum level). **Fig. 2**. | **Photoemission spectroscopy of the lift-off full devices.** Cu 2p XPS depth profiling using gas cluster ion beam (GCIB) sputtering (The sputtering rate for organic f films is about 0.05 nm s⁻¹ using *N,N'*-bis-(1-naphthyl)-*N,N'*-diphenyl-1,1' -biphenyl-4,4' - diamine (NPB) as the reference) detected at the substrate side of (**a**) the fresh control 375 (without YbO_x) sample and (**b**) the aged control sample (after thermal annealing at 80 $^{\circ}$ C in ambient air for 5 h). Control: substrate/perovskite/C60/Cu. **c**, Cu 2p XPS depth profiling detected at the substrate side of the fresh (up) and the aged (bottom) target samples (with YbO_x, after thermal annealing at 80° C in ambient air for 5 h). Target:

 substrate/perovskite/C60/YbO*x*/Cu. Cu LMM Auger spectra were detected at the Cu side of (**d**) the aged control sample and (**e**) the aged target sample (after thermal annealing at 80°C in ambient air for 5 h). The red line at the top shows the spectra difference, and this line is 382 obtained by using the as-delaminated spectrum $(0 \text{ s}, \text{ blue lines at the middle})$ minus $Cu⁰$ reference spectrum (black lines at the bottom)], which can be used to analyze chemical states. **f**, Yb 4d XPS depth profiling measured at the Cu side of the fresh target sample with YbO_x, before and after the accelerated ageing.

 Fig. 3. **| Photovoltaic performance. a**, Schematic illustration of the charge-carrier 387 transport across the $ESL/YbO_x/Cu$ interface. The carrier transport in the YbO_x buffer layer is by phonon-assisted electron hopping from one localized state to another. **b**, Schematic illustration of the device configuration of a typical p-i-n PSCs with the YbO*^x* buffer layer. 390 The magnified area illustrates the amorphous nature of the YbO_x buffer layer used in our p-i-n PSCs. **c-e**, The current density−voltage (*J*−*V*) characteristics of the p-i-n PSCs with various bandgaps and these devices' steady-state power output (SPO) at the maximum power point under simulated AM 1.5 G illumination (inset). NBG, narrow bandgap. MBG, mid-bandgap. WBG, wide bandgap. **f**, Power-conversion-efficiencies (PCEs) distributions for p-i-n PSCs with NBG, MBG, and WBG bandgaps. The number of devices is 15 for 396 each. **g**, Comparison of the *V*_{OC} of state-of-the-art p-i-n PSCs with varied bandgaps. Note that the data from the literature is based on the p-i-n PSCs with the BCP buffer layer. The

 dashed line represents 90% of the radiative limit concerning the bandgap energy. **h**, The external quantum efficiency (EQE) spectra of the champion p-i-n PSCs with NBG, MBG, and WBG perovskites.

Methods

 Materials. Lead diiodide (PbI2, 99%), lead dibromide (PbBr2, 99%), [2-(3,6-dimethoxy-9H-carbazol-9-yl)ethyl]phosphonic Acid (MeO-2PACz) and [2-(9H-Carbazol-9-

Device fabrication. Before device fabrication, the pre-patterned ITO or FTO substrates 450 were ultrasonically cleaned using an aqueous detergent solution, deionized water, acetone, and IPA for 20 min. Subsequently, the as-cleaned ITO and FTO substrates were treated 451 with UV-ozone for 10 min. 452

treatment solution. Then 50-μL of post-treatment solution was dynamically spin-coated on 473 474 top of the perovskite film, followed by annealing at 100° C for 5 min.

487 For the NBG perovskite, the MeO-2PACz (0.5 mg mL⁻¹, in ethanol) solution was spin- coated onto the pre-cleaned FTO substrates at 3,000 r.p.m. for 30 s and annealed at 100°C for 10 min in an N2-filled glove box. The perovskite films were prepared according to the 490 previous work reported elsewhere³.

491 The samples were then transferred to a vacuum chamber to make the charge-selective layer 492 without air exposure. C⁶⁰ (35 nm) was thermally evaporated in a vacuum chamber with a 493 base pressure of $< 4 \times 10^{-4}$ Pa. For the NBG perovskites, the PCBM solution (20 mg mL⁻¹ 494 in CB) was spin-coated on top of the perovskite layer at the speed of 1,000 r.p.m. for 30 s 495 (with a ramping rate of 200 r.p.m. s^{-1}).

496 For the buffer layer fabrication, the samples were transferred to a separate vacuum chamber 497 with a base pressure of $\langle 4 \times 10^{-4}$ Pa. The ytterbium oxide (YbO_x) buffer layer with a 498 thickness of 1.5 nm was obtained by the thermally evaporated metal ytterbium (Yb) in the 499 vacuum chamber. The thermal evaporation rate for the metal ytterbium is 1 Å/s . Note that 500 Yb will be naturally oxidized into the YbO_x in a few minutes without intentional additional 501 oxidation processes. For the control devices with the BCP interlayer, BCP (1 mg mL⁻¹ in for 502 ethanol) was spin-coated at 5,000 r.p.m. with a ramping rate of 2,500 r.p.m. s⁻¹ for 30 s. 503 Finally, a 100-nm thick Cu electrode was thermally evaporated on the samples in the 504 vacuum chamber ($\lt 4\times10^{-4}$ Pa) through a metal shadow mask with an aperture area of 10.3 $505 \, \text{mm}^2$. The aperture mask area for the photovoltaic performance tests is 7.2 mm². Besides, 506 for the WBG and MBG devices, MgF_2 (100 nm) was deposited on the glass side of the ITO 507 substrate as the anti-reflection coating, while for the NBG devices, MgF² (125 nm) was 508 deposited on the glass side of the FTO substrate.

 Stability assessment. For the stabilized power output (SPO) test, the encapsulated devices were measured at the maximum power point (MPP) under full-spectrum white LED illumination (continuous 1-sun illumination) in ambient air or in the N² atmosphere. Thermal stability assessments for encapsulated devices were conducted by storing the encapsulated PSCs on a hot plate at 85℃ in an N² atmosphere. Photovoltaic performances were regularly measured when cooled down to room temperature. For the NBG-containing 515 PSCs, the PCBM electron transport layer was replaced by C_{60} (35 nm, prepared by thermal evaporation) in the thermal stability and long-term MPP tracking assessments. The encapsulation for the device was done by capping the device with a glass slide, using UV 518 adhesive as the sealant. The encapsulation process was finished in an N_2 -filled glovebox 519 (with H₂O and O₂ concentrations of < 0.1 ppm). For the stability test under the ISOS-L-3 protocol, the temperature was controlled and monitored by the polyimide heating film with a digital display in temperature control. The ageing devices adhered to the polyimide heating film.

 measurement system (Enli Technology, Inc.). Electroluminescence (EL) quantum 529 efficiency (EQE_{EL}) was carried out at room temperature (297 K) in an N₂-filled glovebox. A Keithley 2400 Source Meter and an integration sphere (CME-LP38) coupled with a spectrometer (Flame, Ocean Optics) were used for the measurements. The device was placed on top of the integration sphere, and only forward light emission can be collected. The devices were swept from zero bias to forward bias.

 Film characterization. The field-emission scanning electron microscope (FE-SEM) was used to investigate the top-view and cross-sectional morphology with an accelerating voltage of 10 kV (Hitachi U8010). Spin-coating perovskite films on the ITO-coated glass substrates prepared samples for Ultraviolet-visible (UV-vis) absorption spectra characterizations. Then their UV-vis absorption spectra (350-850 nm) were recorded by a spectrophotometer (UH4150, Hitachi, Japan) with the background noise subtracted before testing. During the measuring process, the perovskite films were exposed to air for less than 5 min. The time-resolved photoluminescence (TRPL) spectroscopy measurements were performed by an Edinburgh Instruments FLS1000 photoluminescence spectrometer (Edinburg, UK), and a pulsed laser measured all TRPL-related tests with the excitation wavelength of 450 nm after 120-second illumination. Temperature-dependent current density−voltage (*J*−*V*) characteristics of ITO/[YbO*^x* (5 nm)/Cu (1 nm)]20/Cu and 546 ITO/[YbO_x (2 nm)]₂₀/Cu were measured by using HP4140B picoammeter dominated by

 computer within a cryostat. Both devices processed by evaporating 20 alternative layers. 548 For $[YbO_x (5 \text{ nm})/Cu (1 \text{ nm})]_{20}$, we mean we have deposited 20 alternating layers of 5 nm YbO_x followed by 1 nm Cu. The starting low temperature is 80 K cooled with liquid nitrogen, and data was acquired by every 30 K increase controlled by MercuryiTC low temperature environment controller. Grazing incidence wide-angle X-ray scattering (GIWAXS) measurements for amorphous Yb films deposited on various substrates were conducted at the BL17B1 beamline of Shanghai Synchrotron Radiation Facility (SSRF). 554 The X-ray wavelength was 1.240 Å with a grazing incident angle of 1.0 degree, and the scattering intensity was detected by a PILATUS 2M detector. Thermo Scientific ESCALAB Xi^{+} system was used to acquire the X-ray photoelectron spectroscopy (XPS), ultraviolet photoelectron spectroscopy (UPS), and the reflection

 electron energy loss spectroscopy (REELS) spectra. All samples were transferred into the analysis chamber via a vacuum transfer module avoiding exposure to the air. Unless otherwise stated, the gas cluster ion beam (GCIB) sputtering technology carried out the 561 depth profiles with the parameters of 2000-cluster sizes at 4 keV ion energy. Ar^+ ion sputtering was used as a supplement to etch the hard materials, such as metal electrodes. High-resolution transmission electron microscopy (HRTEM) and annular dark-field scanning transmission electron microscopy (ADF-STEM) images have been obtained by using a JEM-2100F field emission gun microscope with a 0.19 nm point‐to‐point resolution

Data and materials availability

 All data are available in the main text or the supplementary materials, and are also available from the corresponding author on reasonable request

Acknowledgments

 This work was financially supported by the Natural Science Foundation of China (52325310, 52203208), the Beijing Natural Science Foundation (JQ21005), the National Key R&D Program of China (2021YFB3800100, 2021YFB3800101), the Science and Technology Project of Southwest Joint Graduate School of Yunnan Province (Research on

Author contributions

- D.L., Z.-H.L., P.C., Y.X., and R.Z. conceived the idea and designed the experiments. P.C.,
- Y.X., S.L. X.J., and T.H. fabricated PSCs and characterized photovoltaic performances.
- P.C. and M.Y. performed electroluminescence tests. Y.X., P.K., and Pietro. C. contributed
- to the analysis of electroluminescence results. X.L. conducted EQE measurements. J.H.,
- J.W., Y.S., and P.T. conducted the TEM and EDX tests. J.H. and N.C. performed REELS,
- UPS, and XPS measurements. J.H., N.C., D.W., D.L., R.S., and Z.-H.L. contributed to
- analyzing REELS, UPS, and XPS results. N.C. and Z-H.L. contributed to the analysis of
- charge transport mechanisms. J.H., P.C., Y.X., and Q.L. conducted the SEM

- measured UV-Vis light absorption. C.-H.H., Y-W.Y., and J.-J.S. performed TOF-SIMS
- measurements. P.C., Y.X, and Q.Z. performed the TRPL test and did data analysis. H.Y.,
- Y.X., and P.C. conducted the stability test. D.L., Q.G., Z.-H.L., H.J.S., and R.Z. directed
- and supervised the project. P.C. and Y.X. wrote the first draft of the paper. D.L., Q.G., Z.-
- H.L., H.J.S., and R.Z. revised the paper. All authors analyzed their data, reviewed and
- commented on the paper.

Conflict of interest

- Henry J. Snaith is the founder and Chief Scientific Officer of Oxford Photovoltaics, a
- company commercializing perovskite photovoltaics.

Extended data figure legends

 Extended Data Fig. 1 | **Overview of buffer layers. a**, Schematic illustration of the functions of an ideal buffer layer between the electron-selective layer (ESL) and the metal electrode, showing suppression of the harmful species movement and the non-radiative recombination. **b**, Standard molar Gibbs free energy (Δ*f*G) of formation at 298.15 K in kJ μ mol⁻¹ of representative metal oxides including ZnO, SnO₂, ZnSnO₄, TiO₂, Cr₂O₃, and Yb2O3. **c**, Schematic illustration of the thermal evaporation deposition process of the metal Yb.

Extended Data Fig. 3 | **XPS measurements and photographs of Yb bulk and YbO***^x*

surface. a, Yb 4d XPS spectrum of the Yb bulk with 2400 s Ar ion etching. Photographs

630 of the pristine Yb bulk with a naturally oxidized YbO_x surface (**b**) and the polished Yb bulk

(**c**) in ambient air. The color change indicates that the refreshed metal Yb surface would

632 quickly react with oxygen upon oxygen exposure, forming YbO_x on the surface.

 Extended Data Fig. 4 | **The oxidization process of Yb. a**, Yb 4d XPS spectrum of an as- prepared ITO/YbO*^x* (1.5 nm) film. The sample was immediately transferred from the physical vapor deposition system to the XPS chamber by the vacuum transfer module 636 without exposure to the air. **b**, Yb 4d XPS spectra of a clean Yb^0 surface spontaneously oxidized in the UHV XPS chamber. L represents Langmuir. **c**, The YbO*^x* thickness and Yb^{3+}/Yb^0 ratios as a function of the exposure dose. **d-i**, Yb 4d XPS spectra with increased exposure dose.

Extended Data Fig. 5 | **Transmission electron microscopy (TEM) measurements. a, b,**

TEM images of YbO*^x* directly deposited on the carbon-supported copper (50 and 20 nm).

642 c, The typical fast Fourier transform (FFT) spectrum $(30 \times 30 \text{ nm}^2 \text{ area})$ indicates the

amorphous crystal structure of YbO*x*.

Extended Data Fig. 6 | **2D grazing incidence wide-angle X-ray scattering (GIWAXS)**

- 645 **measurements.** The 2D GIWAXS patterns at an incidence angle of 1.0° for YbO_x films
- prepared on different substrates including silicon (**a**), glass (**b**), and ITO-coated glass (**c**),
- 647 respectively. The thickness of the deposited YbO_x film for this measurement is 10 nm. **d**,
- The 2D GIWAXS pattern of the pristine ITO-coated glass.

Extended Data Fig. 7 | **Gap states in the YbO***^x* **film and charge-carrier transport**

measurements. a, Yb 4d XPS spectra of the YbO*^x* film with a thickness of 40 nm. **b**,

Valence band spectra of YbO*x*. There exists a considerable density of gap states below the

- Fermi level. **c**, Current density−voltage characteristics of the ITO/[YbO*^x* (2 nm)]20/Cu over
- temperature ranged from 120 K to 300 K. Note that the 40 nm YbO*^x* deposition is
- completed by evaporating 20 alternative layers. **d**, The plot of conductivity against
- temperature. The conductivity is calculated at 26 mA cm⁻², where the injected current is
- equal to the short-circuit current of a narrow-bandgap PSC under 1-sun illumination. Note

that the pre-factor $σ_0 = (2.22 \pm 0.47) \times 10^{-3}$ S m⁻¹, and the characteristic parameter *B* = 658 10.33 ± 0.81 .

 Extended Data Fig. 8 | **Charge-carrier transport measurements. a**, Current density−voltage characteristics of the device with a configuration of ITO/[YbO*^x* (5 nm)/Cu (1 nm)]20/Cu over temperature ranged from 110 K to 290 K. **b,** The plot of conductivity against temperature.

Extended Data Fig. 9 | **Time-of-flight secondary ion mass spectrometry (TOF-SIMS)**

664 **measurements.** TOF-SIMS depth profiles of the BCP- or YbO_x -based PSCs with and

without ageing. **a, c,** are the control (with the BCP buffer layer) and target device (with the

- YbO*^x* buffer layer), respectively. **b, d,** are TOF-SIMS profiles of both control and target
- 667 devices after ageing at 85° C for 200 h in the N₂ atmosphere, respectively. The highlighted

668 secondary ion distribution: 1: Cs^+ ; 2: Rb^+ ; 3: Cu^+ , 4: I^+ ; 5: Br^+ .

 Extendend Data Table 1 | Photovoltaic parameters. Summary of photovoltaic parameters for the champion p-i-n PSCs with NBG (1.54 eV), MBG (1.59 eV), and WBG perovskites (1.77 eV). The devices were measured from reverse scans (RS) under simulated 672 AM 1.5G solar irradiation at 100 mW cm⁻². For p-i-n PSCs with WBG perovskites, RS is from 1.35 V to –0.02 V. For p-i-n PSCs with NBG and MBG perovskites, RS is from 1.22

674 V to -0.02 V).

675 The average device parameters and standard deviations are based on 15 devices.

Bandgap (eV)

Wavelength (nm)

Thermally activated hopping **a b**

